

Additive Manufacturing Packaging Applications and Growth Needs for Heterogeneous Integration Impact

Kris Erickson

Research Manager, Materials Development

Feb 2024



Agenda

- 1. Additive Manufactured Electronics (AME) & Heterogenous Integration (HI)**
- 2. AME Benefits**
- 3. AME for XR**
- 4. AME Manufacturing & Materials**
- 5. AME Advances & Applications towards Future Electronics & HI**
- 6. AME Growth Needs**

--	--	--	--	--	--	--	--	--

Large collaborative team for creating full content!

Finalizing as a Chapter within HIR 2024

Technical Working Group Contributing Members



Kris Erickson
(Meta)



Eric Dede
(Toyota Research
Institute of North
America)



Jarrid Wittkopf
(HP Labs)



Christine Kallmayer
(Fraunhofer IZM)



Dishit Parekh
(Intel)



Alex Cook
(Nextflex)



Jeroen van den
Brand
(Holst Center)



Mike Newton
(Sciperio)



Annette Teng
(Promex)



David Bowen
(Laboratory for Physical
Sciences)



Mark Poliks
(Binghamton U)



Girish Wable
(Jabil)



Martin Hedges
(Neotech AMT)



Dean Turnbaugh
(NTV)



David Weins
(Siemens)



Richard Neill
(ADVPES)



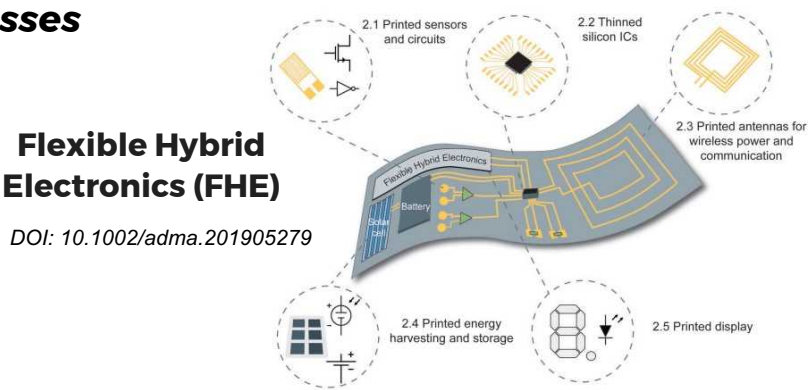
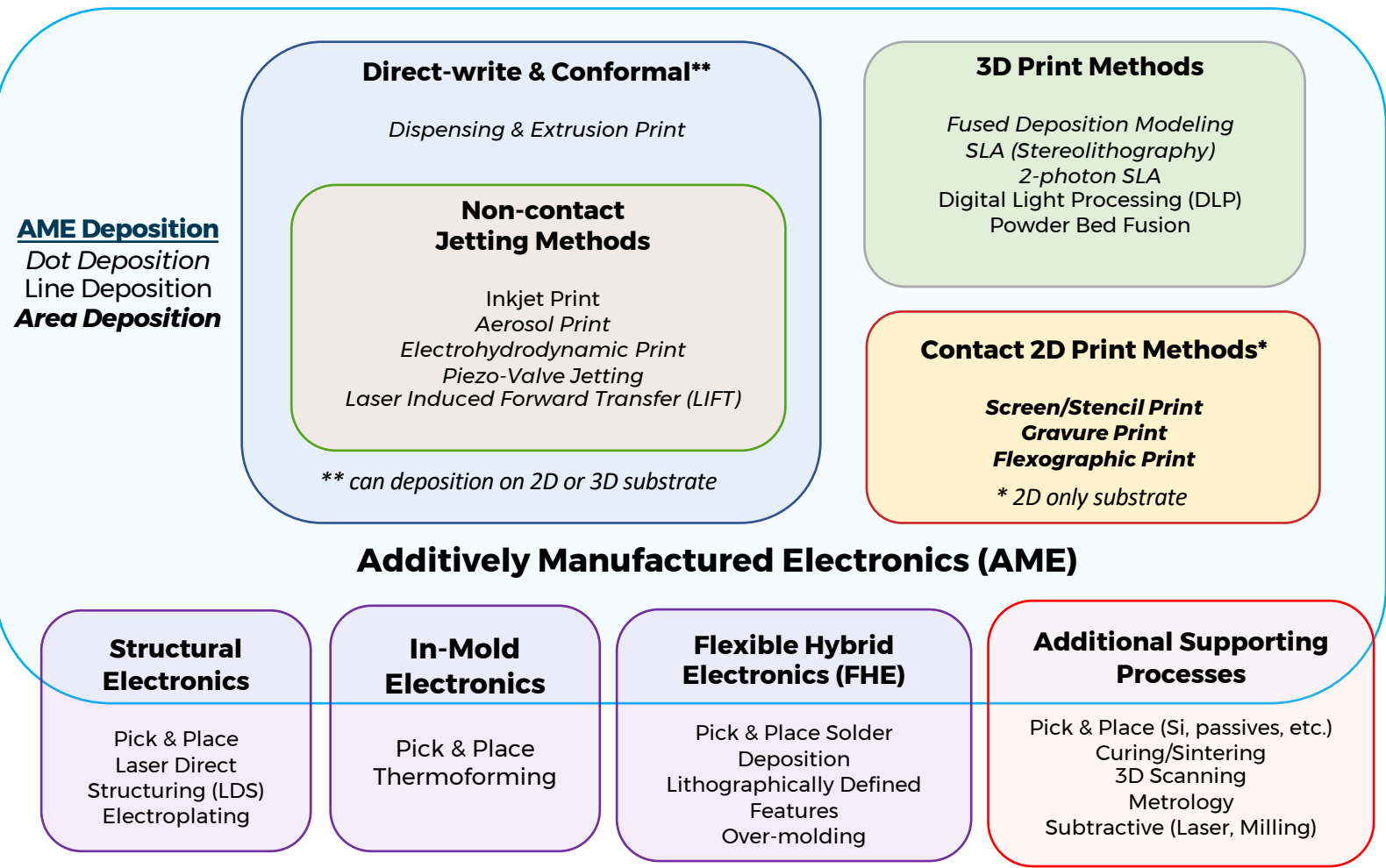
David Rosenfeld
(Celanese)



Markus Scheibel
(Heraeus)

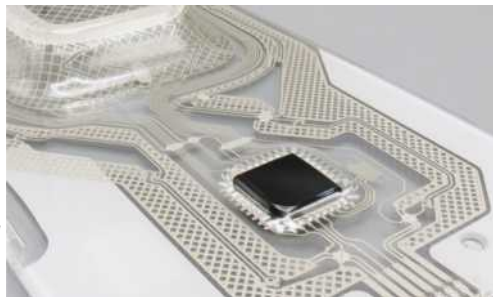
Additively Manufactured Electronics (AME)

AME = Printed Conductor + (Printed/Existing) Dielectric + (optional) Additional Processes



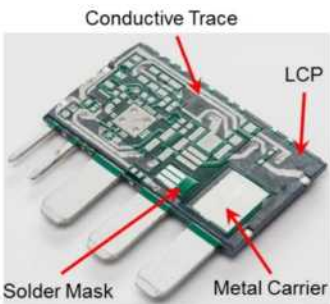
Flexible Hybrid Electronics (FHE)

DOI: 10.1002/adma.201905279



In-Mold Electronics

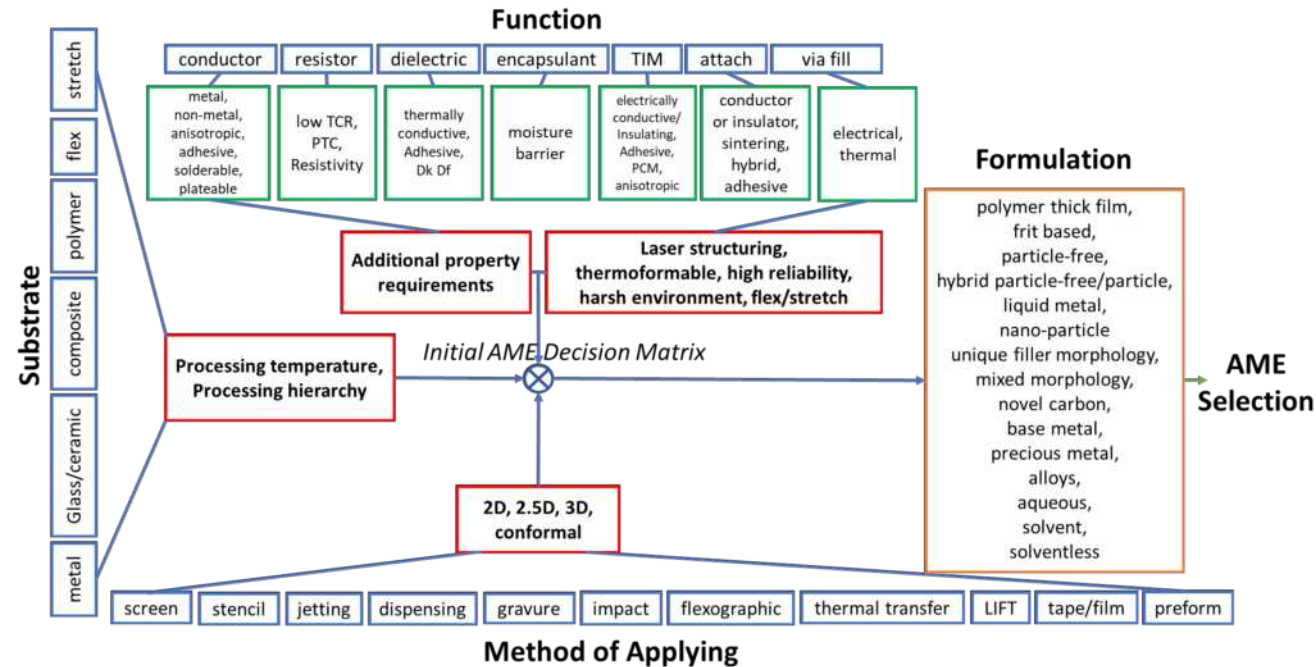
Project "Origami", 02/2018 - 01/2021,
Innovations with Organic 3D Electronics.
#thanks & with permissions from
@Christine Kallmayer and Fraunhofer IZM



Structural Electronics

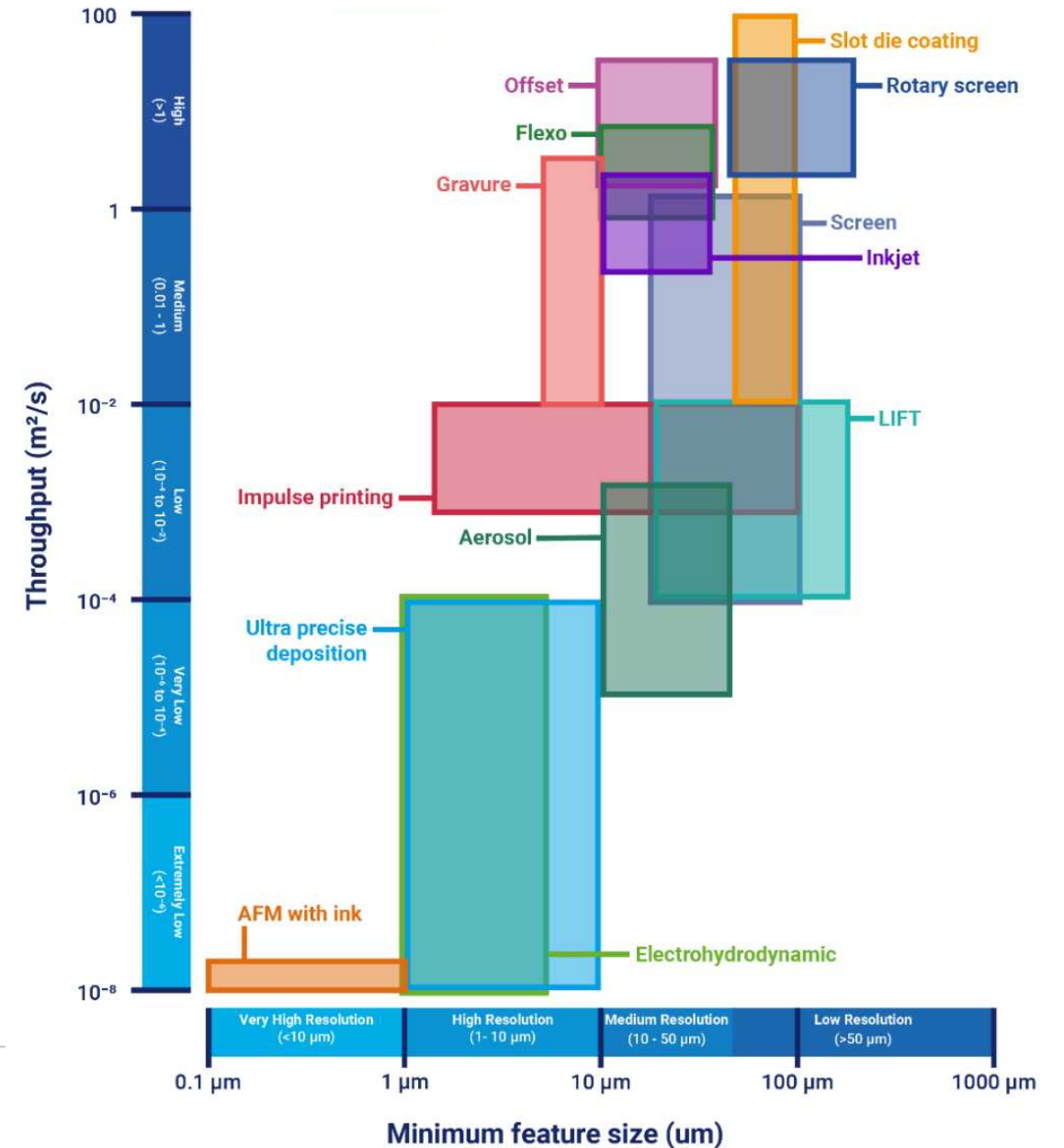
DOI: 10.1109/MID50463.2021.9361621

AME Considerations

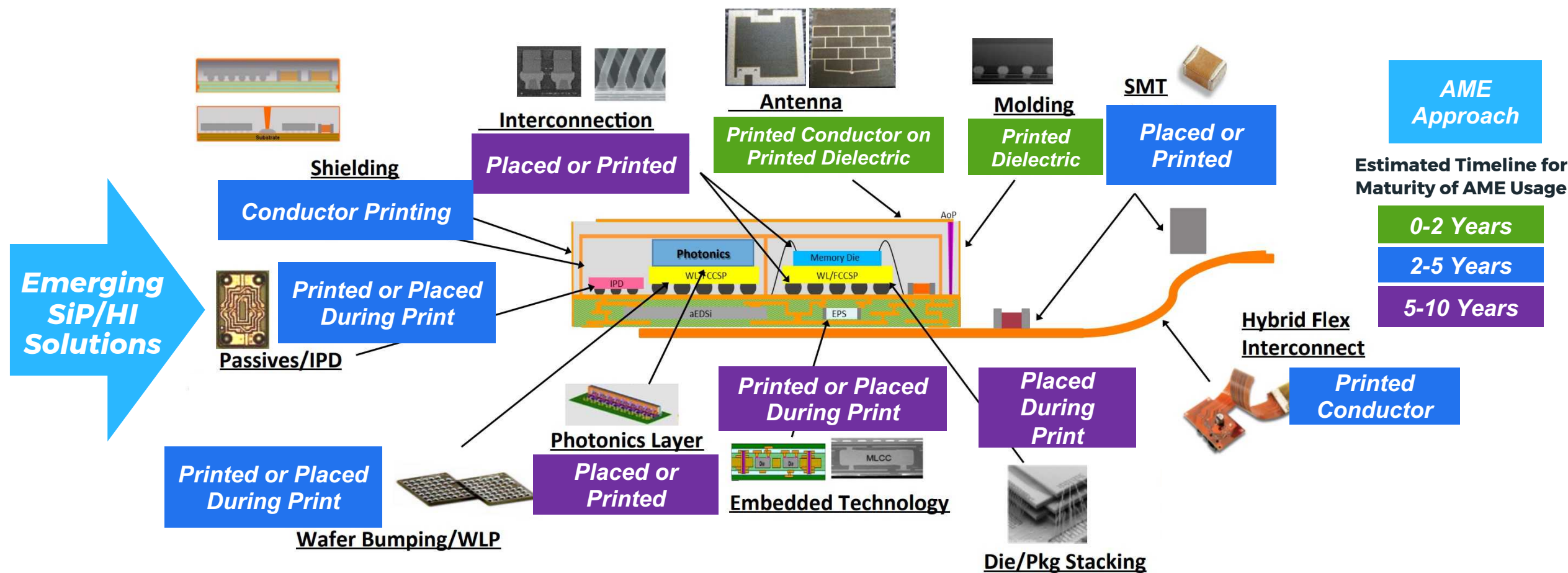


#thanks to Dave Rosenfeld, Celanese, and AME for HIR group

Printing Methods for Electronics: Resolution vs Throughput



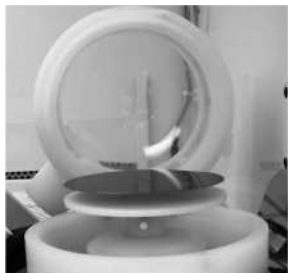
AME for Heterogenous Integration (HI)



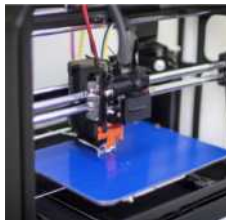
[HIR 2021 version (eps.ieee.org/hir), Ch. 8, Single and Multichip Integration]
In-progress 2024 on HIR Chapter on AME

AME Benefits

Material efficiency

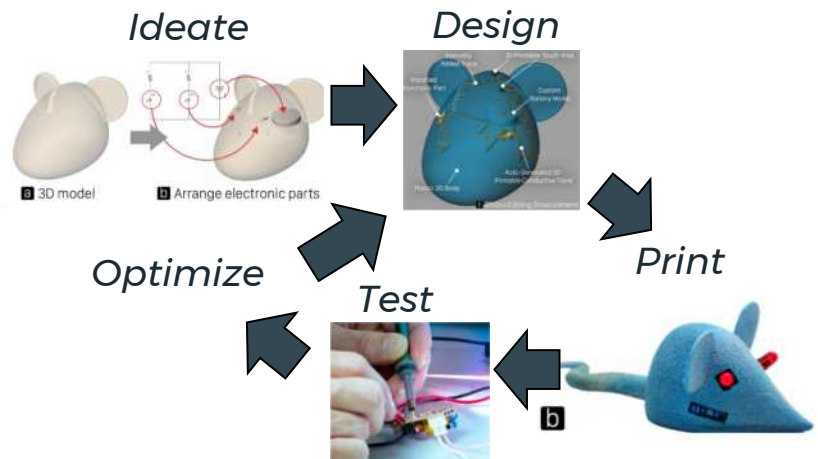


VS.



[https://commons.wikimedia.org/wiki]

Design Freedom & Rapid Prototyping



[ModElec: A Design Tool for Prototyping Physical Computing Devices Using Conductive 3D Printing, L He, et al - Proceedings of the ACM on Interactive, 2021]

Novel Form Factors



DOI: 10.29026/oea.2018.170004

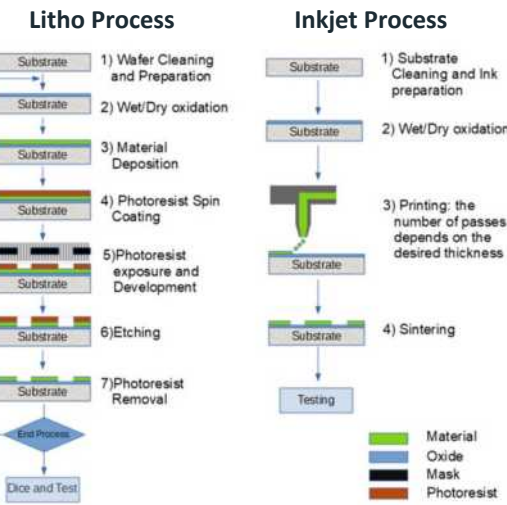
Simplified Manufacturing



VS. **



#thanks and with permissions from @Martin Hedges (Neotech AMT)



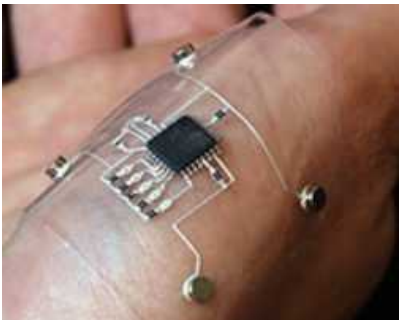
<https://doi.org/10.1002/adem.202000679>

Low-volume/ Individualized Designs



DOI 10.1186/s13104-015-0971-9

Flex/Wearable Devices



<https://doi.org/10.1002/adma.201703817>

AME for Extended Reality (XR)

EMG Wristband



<https://tech.facebook.com/reality-labs/2021/3/inside-facebook-reality-labs-wrist-based-interaction-for-the-next-computing-platform/>

Haptic Glove



<https://about.fb.com/news/2021/11/reality-labs-haptic-gloves-research/>



Fused Deposition Modeling for AME

Down to ~100 micron features (~250 w/o micromachining), alternative conductor deposition methods typical, creating full 3D structures

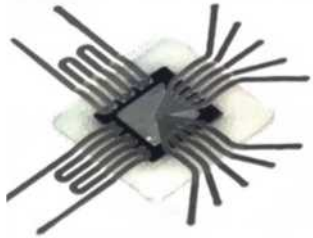
Neotech AMT

Combined, hybrid system

- FDM printing
- Direct write/Syringe
- 5-axis, Conformal Inkjet
- 5-axis, Conformal Aerosol Jet
- Laser sintering

QFN (Quad Flat No-lead) Microcontroller

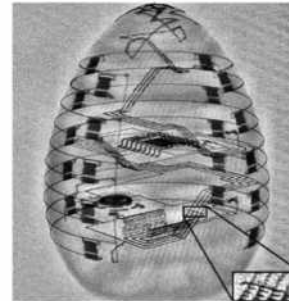
Interconnect/Circuit 230µm in Ag, Fixed with 2 Component Epoxy



Embedded in PC



Surface mounted on glass



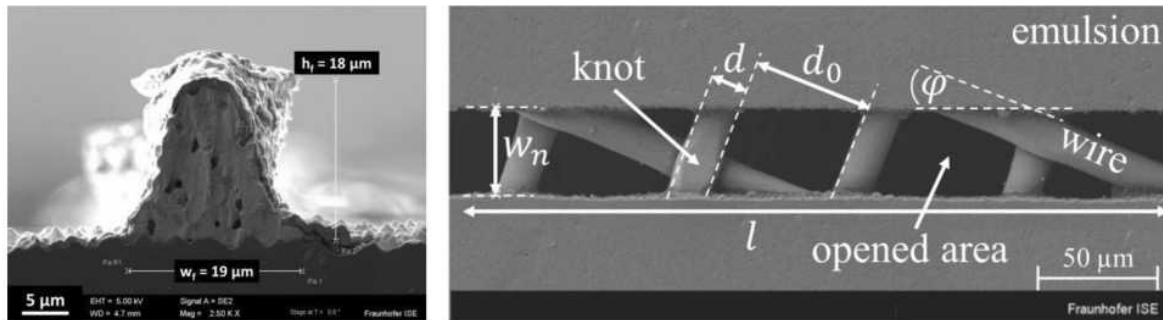
[M. Ankenbrand, et al. 2019 International Conference on Electronics Packaging (ICEP), 2019, pp. 273-278]

DOI: 10.29026/oea.2018.170004

Screen Print for AME

High speed, panel processing, typically to 50 micron features

Pushing Resolution for High Throughput Screen Print



<https://doi.org/10.1038/s41598-021-83275-0>

<= 20 micron feature demonstrations

Fraunhofer ISE, Asada Mesh

Continued Scaling for High Throughput

e.g. Applied Materials – Tempo Presto PE Screen Printer

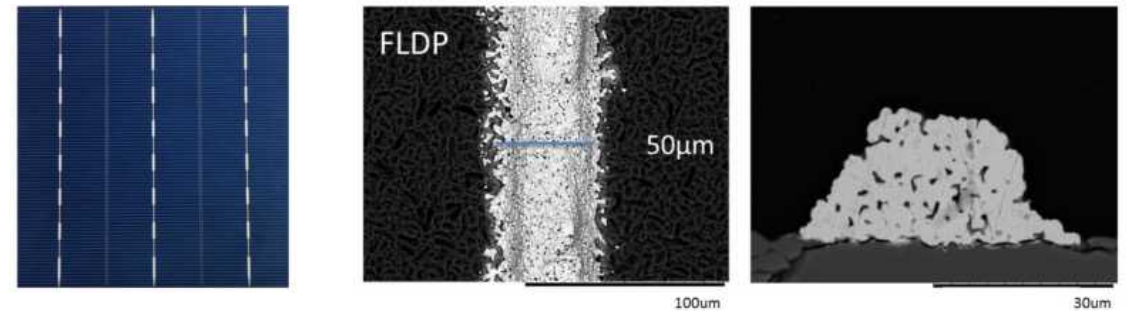
High productivity 8,000 wafers/hr

High Repeatability +/- 5 micron

3 Continuous line Modules – Load, Print, Unload/Dry/Clean

Integrated: Profilometry, Alignment, Electrical Inspection

Solar Cell Metallization Applications

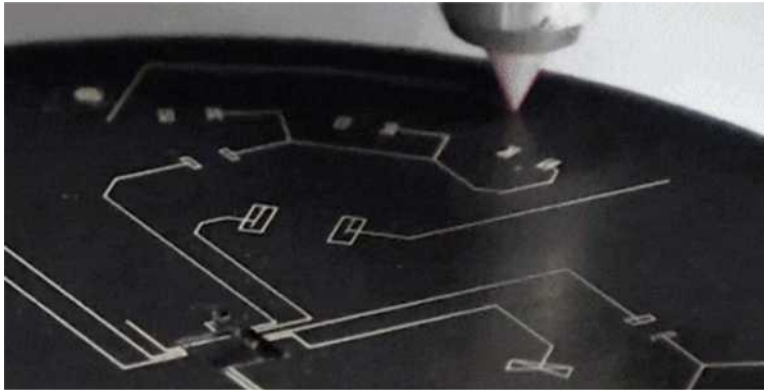


doi: 10.1016/j.egypro.2015.07.074

Direct Write Dispense for AME

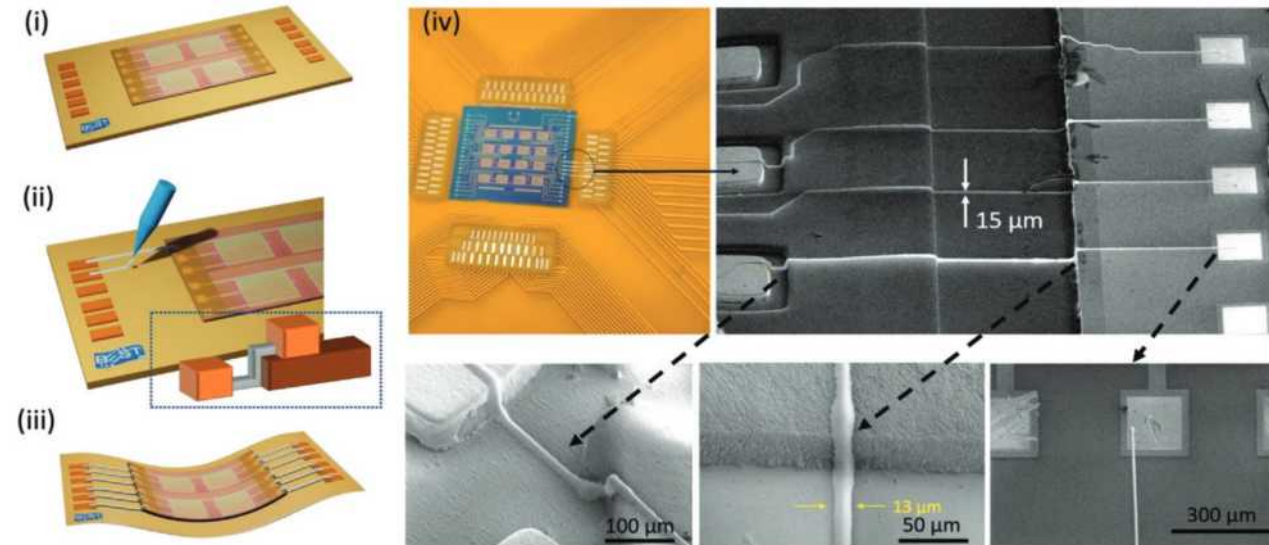
Down to ~15 micron features, high viscosity inks, patterning over topologies

nScript



[<https://www.nscript.com/>]
#thanks and with permissions from Mike Newton, nScript

XTPL



Traces over substrate & chip steps
Wire-bond alternative

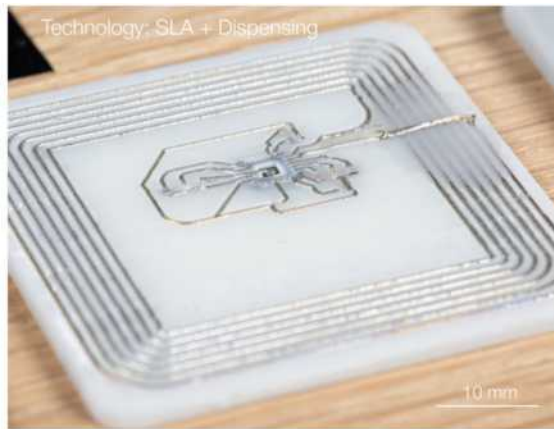
DOI: 10.1002/aelm.202101029

Stereolithography (SLA) for AME

Down to ~100 micron features, alternative conductor deposition methods, creating full 3D structures

TNO Holst

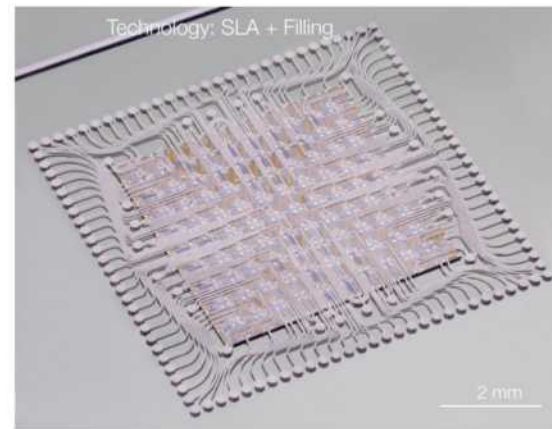
SLA + Dispense



Self-harvesting NFC tag with temperature sensor

*[<https://executivereport.holstcentre.com/innovation-updates/enabling-technologies/3d-printed-electronics/>]
#thanks and with permissions from Jeroen van den Brand and Holst Center*

Modified SLA-Rake Process

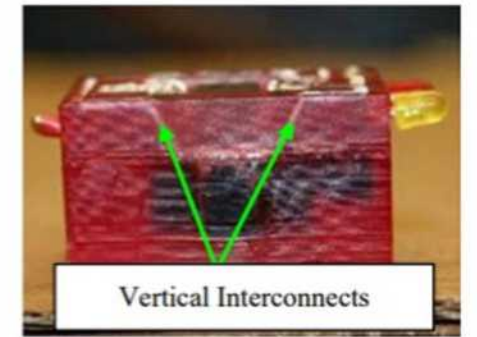
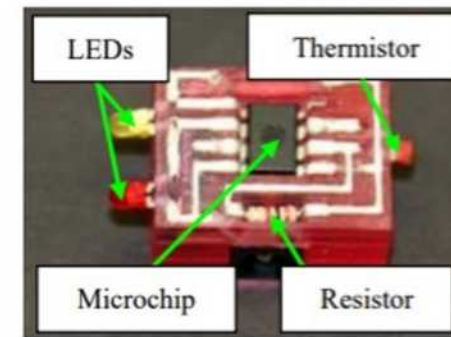


Fanout structure with 220 interconnects

UT - El Paso

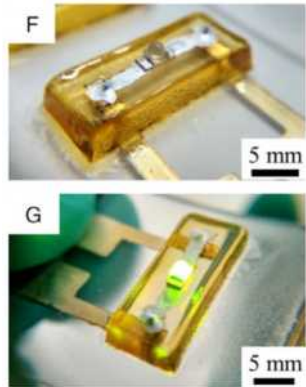
MacDonald Group - Keck Center

SLA, DW + Pick and Place Components



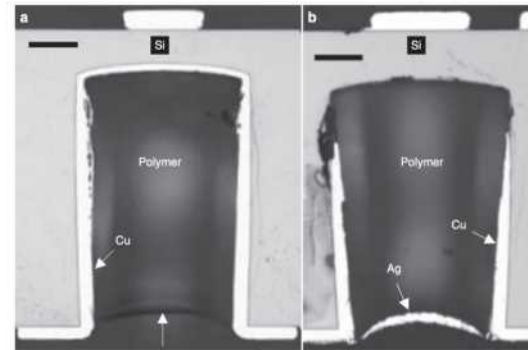
*[D. Espalin, E. MacDonald. Int J Adv Manuf Technol **72**, 963–978 (2014)]*

Inkjet for AME



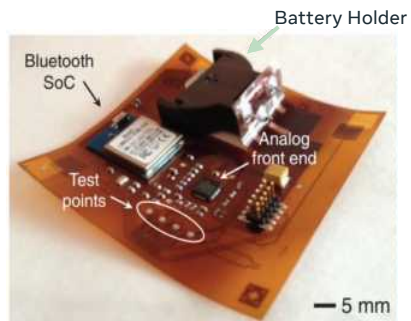
Inkjet Vertical Interconnects

DOI: 10.1002/adem.201900568



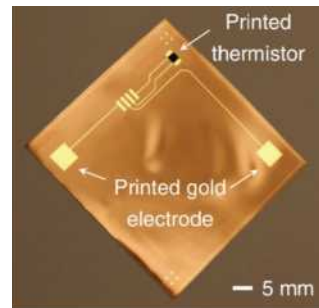
Inkjet filled & planarized TSV → increase I/O Density

doi.org/10.1038/micronano.2017.2



Wearable Health Monitoring - electrodes, thermistors

<https://doi.org/10.1002/adfm.201603763>



Example Application Areas

- Multilayer PCB-board applications
- Selective Solder masks for PCB
- Panel etching mask
- Encapsulation layers
- Dielectric, Conductor, Adhesive, and/or Mask Resist for Semiconductor Back-End Packaging
- Integratable with P&P methods
- Antenna Printing

Commercial Examples

NanoDimension

Dragonfly

Down to 75 micron features, 150 micron interconnects, min layer thickness 3 micron, multi-layer PCB builds

ChemCubed

ElectroJet

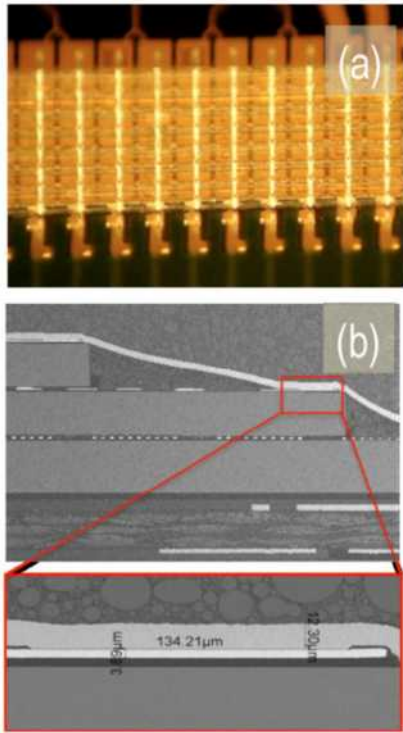
Suss PiXDRO

Down to 20 micron features

- Multiple commercial printheads
- In-line curing
- Precision substrate manipulation
- Automated Print Optimizations
- Gerber files → Inkjet Bitmap
- Material efficiency vs. standard coat + etch
- Up to 1200 wafers/hr (Jetx-P) or 80 panels/hr (Jetx-M)

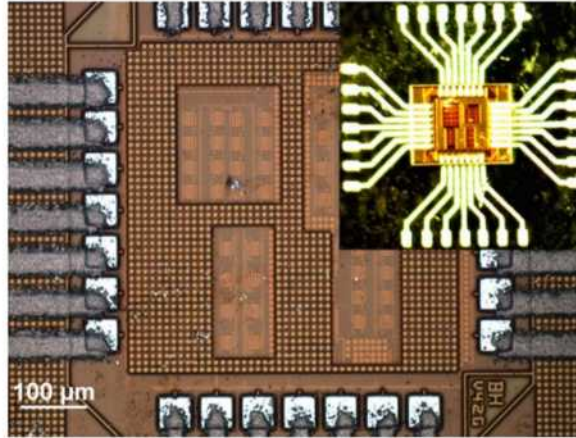
Aerosol Printing for AME

To 20 micron features, multi-materials, printing over topologies



Wire-bond Replacement

Hedges, Martin, and Aaron Borrás Marin. "3D aerosol jet printing-adding electronics functionality to RP/RM." DDMC 2012 conference. 2012.



Print on un-Packaged Bare-die

Additional Applications

- High Frequency RF Interconnects
- Printed RDLs
- Package-level Shielding
- Printed Antennas

Commercial Examples

Optomec

Aerosol Jet 5X 3D Printer

IDS

NanoJet Systems

Electrohydrodynamic Jet for AME

*High Resolution (at or below 1 micron features),
wide ink viscosity range*

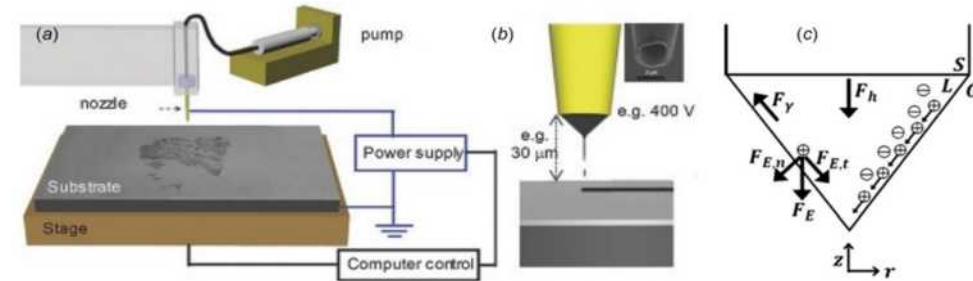
Commercial Examples

Super InkJet

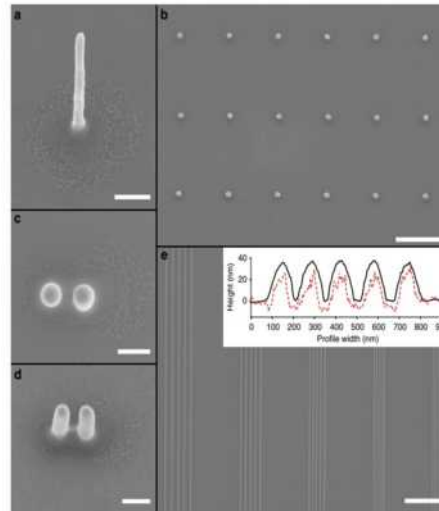
1 micron line/space

Scrona

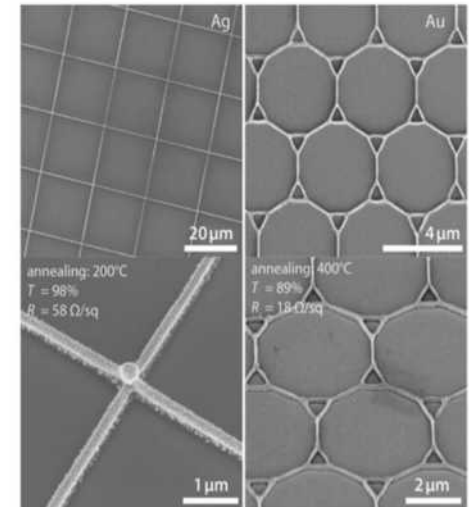
*Multi-Nozzle, Annular Anode, down to 500 nm
features, up to 10K cP inks*



DOI: 10.1115/1.4041934

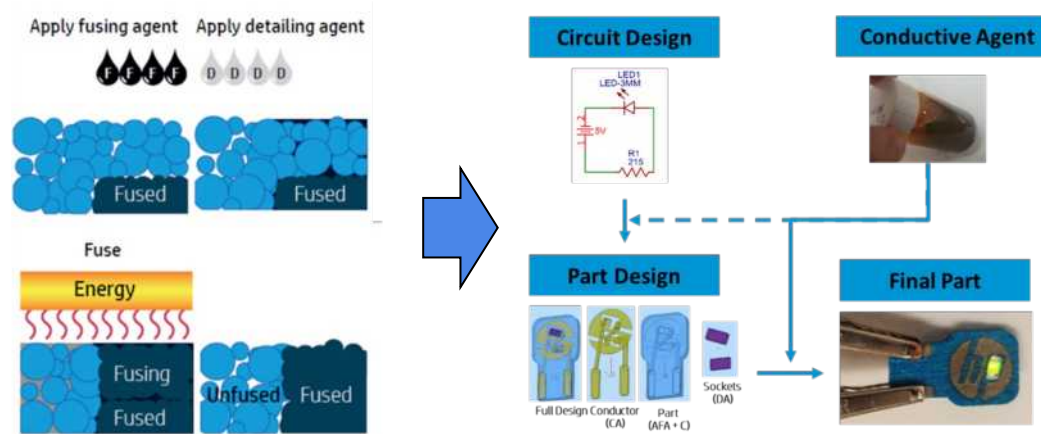


DOI: 10.1038/ncomms1891

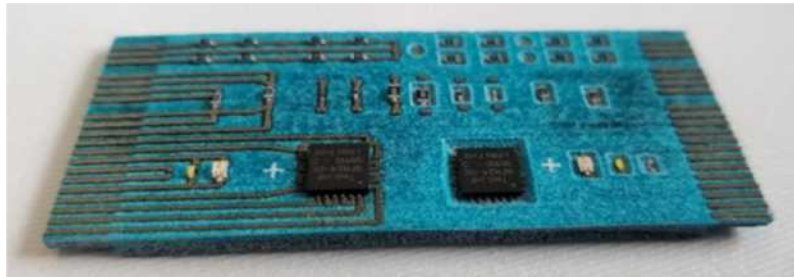


<https://doi.org/10.1515/ntrev-2021-0073>

Powder Bed Fusion for AME



[Techblick.com: **HP | 3D Printing of Electronics using Multi Jet Fusion**]
#thanks and with permissions from Jarrod Wittkopf, HP Inc.



[Techblick.com: **HP | 3D Printing of Electronics using Multi Jet Fusion**]
#thanks and with permissions from Jarrod Wittkopf, HP Inc.



[L. He, J. Wittkopf. Proc. ACM Interact. Mob. Wearable Ubiquitous Technol., Vol.5, No.4, Article159]

AME Advances Materials

FORM

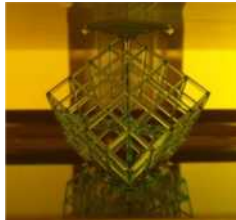
Highly tailored per manufacturing approach



[<https://www.shutterstock.com/>]

Filaments

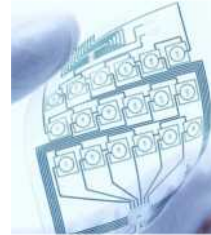
FDM



[<https://www.shutterstock.com/>]

Photo-resins

SLA, DLP



[<https://www.shutterstock.com/>]

Films/Sheets

Screen, Stencil, Gravure, Flexo



[<https://www.shutterstock.com/>]

Powders

Powder Bed Fusion



Inks

Inkjet, Aerosol, EHD



Pastes

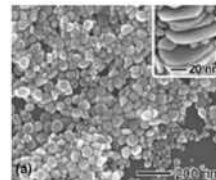
Dispense, Screen, Stencil,
Gravure, Flexo, Piezo-Valve

FUNCTION

Conductors

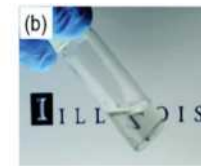
Traces, Interconnects, Vias, Antenna

Silver-based



DOI: 10.1007/s11665-014-1166-6

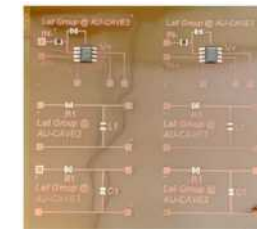
Nano/Micro-particle



DOI: 10.1039/c9tc05463d

Metal Salt

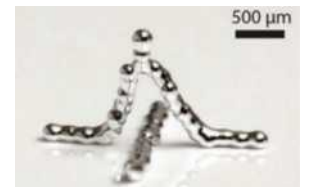
Copper-based



DOI:10.1109/iTherm5
4085.2022.9899673

Flex-Stretch

Micron-Ag + Elastomer



doi.org/10.1002/admt.202000070

Liquid-Metal based

Dielectrics

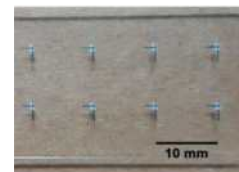
Substrate, Packaging, Shielding, Capacitors

Flex/Stretch Substrates

PET, TPUs, Silicones, Beyolux, etc.



[<https://www.shutterstock.com/>]



doi:10.1021/acsnano.8b06464

Cross-over & High-K Dielectrics

For multiple trace layers or capacitors

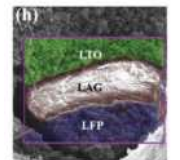
Specialized

Sensors, Resistive, Batteries, Optical, etc.



doi:10.1109/jsen.2020.2976508

Force Sensors



<https://doi.org/10.1002/adfm.201906244>

Batteries

AME Advances Manufacturing Integration & Productivity

Manufacturing Integration

Fraunhofer IPA - Next Factory

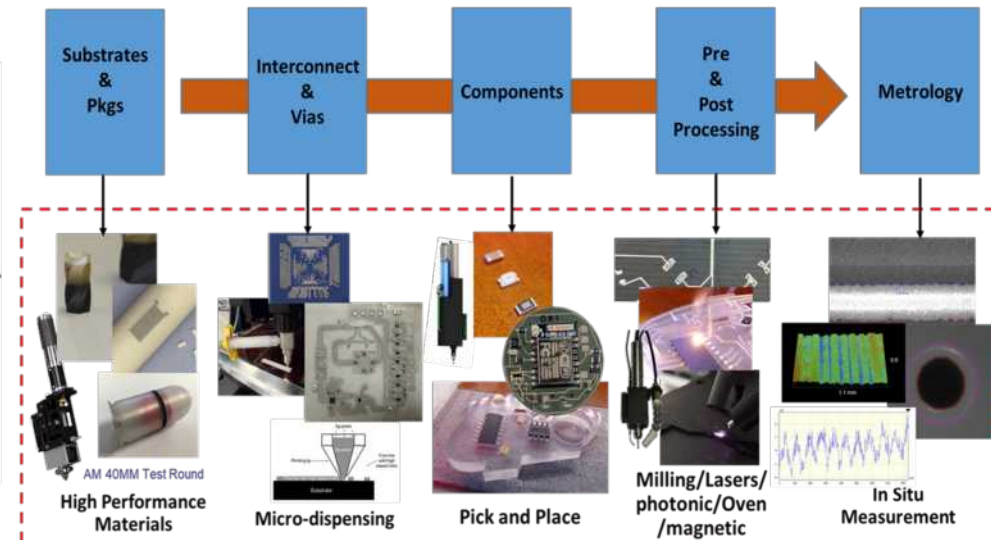
IJ + Cure/Sinter + Planarize + P&P/Assembly + Measurement/Inspect
100X100X50 mm build area; 10 micron layers, 150/250 micron I/s



[\[https://doi.org/10.1016/j.microrel.2018.04.008\]](https://doi.org/10.1016/j.microrel.2018.04.008)

nScript

FDM + DW + P&P + Milling + Curing + Measurement



#thanks & with permissions from Mike Newton & nScript

Integration & Productivity

Screen Print

Up to 8K Wafers/hr Tempo Presto PE Screen Printer
Integrated Profilometry, Alignment, Electrical Inspection, Wafer Load/Unload/Clean

Inkjet Print

Up to 1.2K Wafers/hr Suss PiXDRO
Integrated Curing, Alignment

AME HI Applications Flex Use-case

#thanks and with permissions from Girish Wable, Jabil

RIGID PCBA



Board: Rigid FR4

Subtractive process

Copper traces

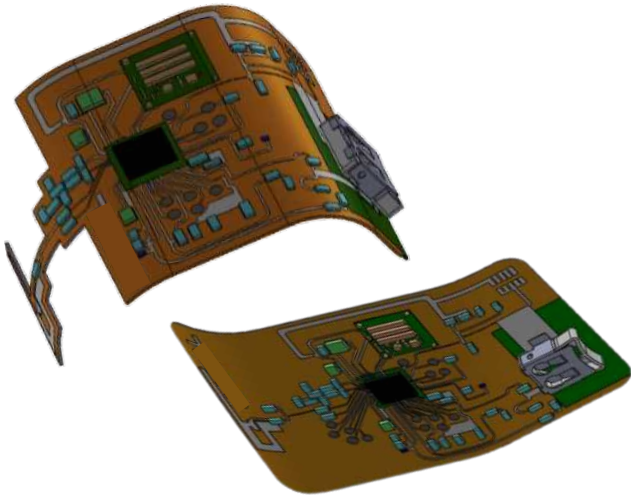
Weight (board): 17 grams

Assembly Temperature – 220 – 250 deg c

Cost: Baseline

PCF - Baseline

RIGID-FLEX or FLEX PCBA



Flexible Polyimide Substrate

Subtractive process

Copper traces

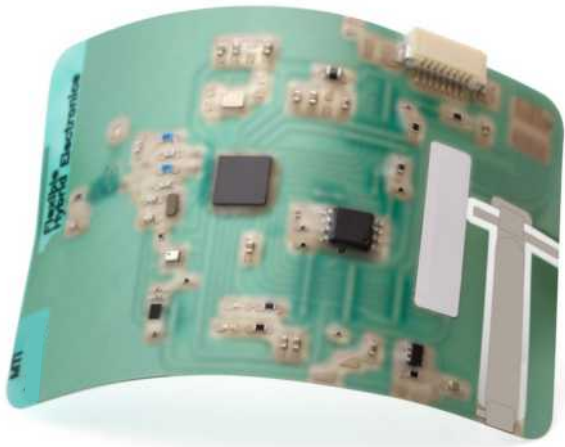
Weight: 6 grams

Assembly Temperature – 220 – 250 deg c

Cost: Higher

PCF - Baseline

FLEXIBLE HYBRID ELECTRONICS



Flexible Plastic Substrates

Printing (additive) process

Silver/Copper traces, Sensors

Weight: 2 grams

Assembly Temperature – 120 deg c

Cost*

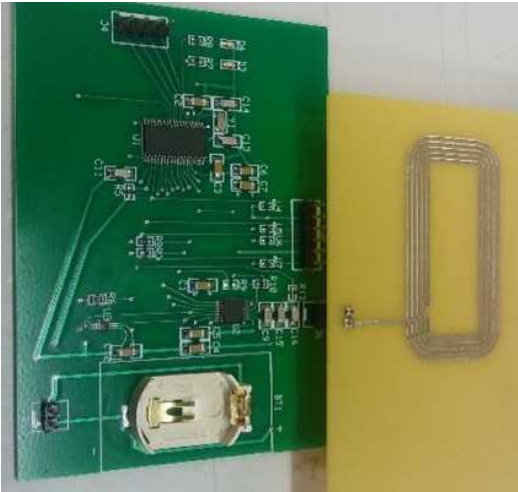
Lower compared to Rigid Flex or Flex

PCF – Significantly Better*

* - more data needed

Benefits Leveraging Weight Temperature Cost Flexible

AME HI Applications Wearable Use-case



VALUE TRANSFORMATION

FLEXIBLE BENDABLE CONFORMAL

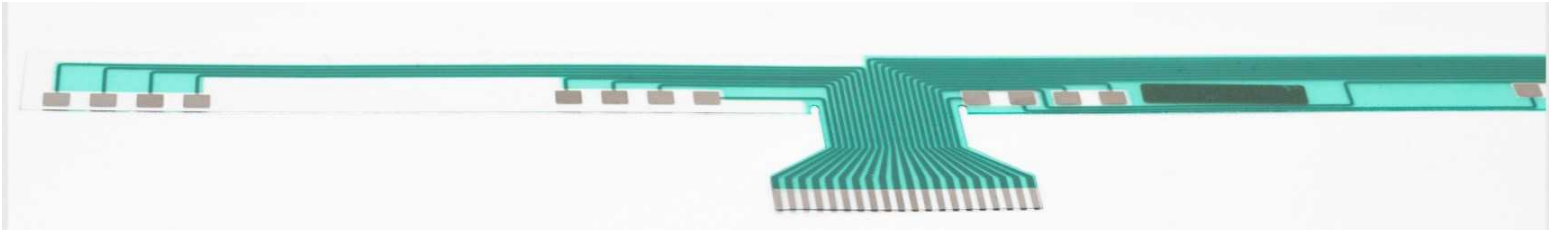
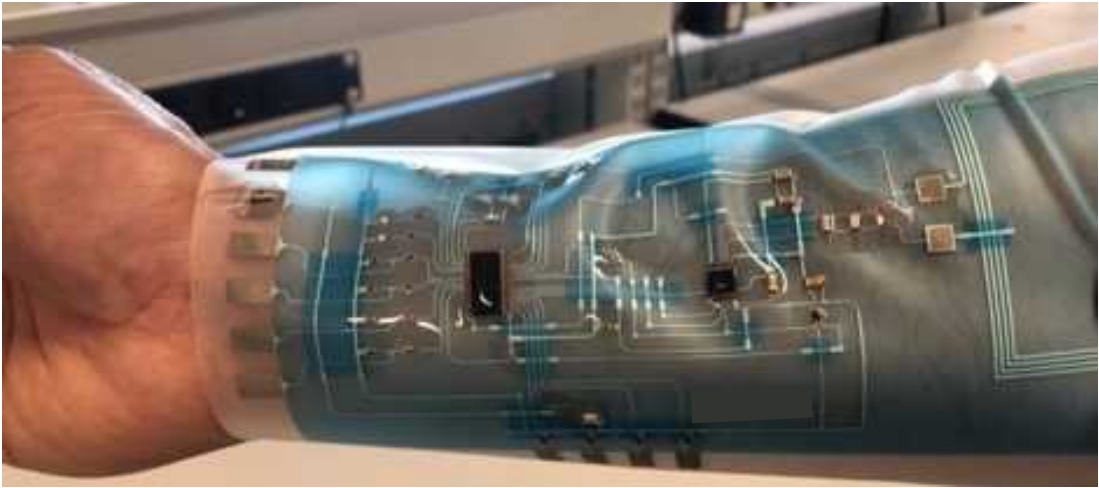
STRETCHABLE LIGHT TWISTABLE

THIN DIRECT-DEPOSITED 3D

COST BENEFITS

BOM CONSOLIDATION

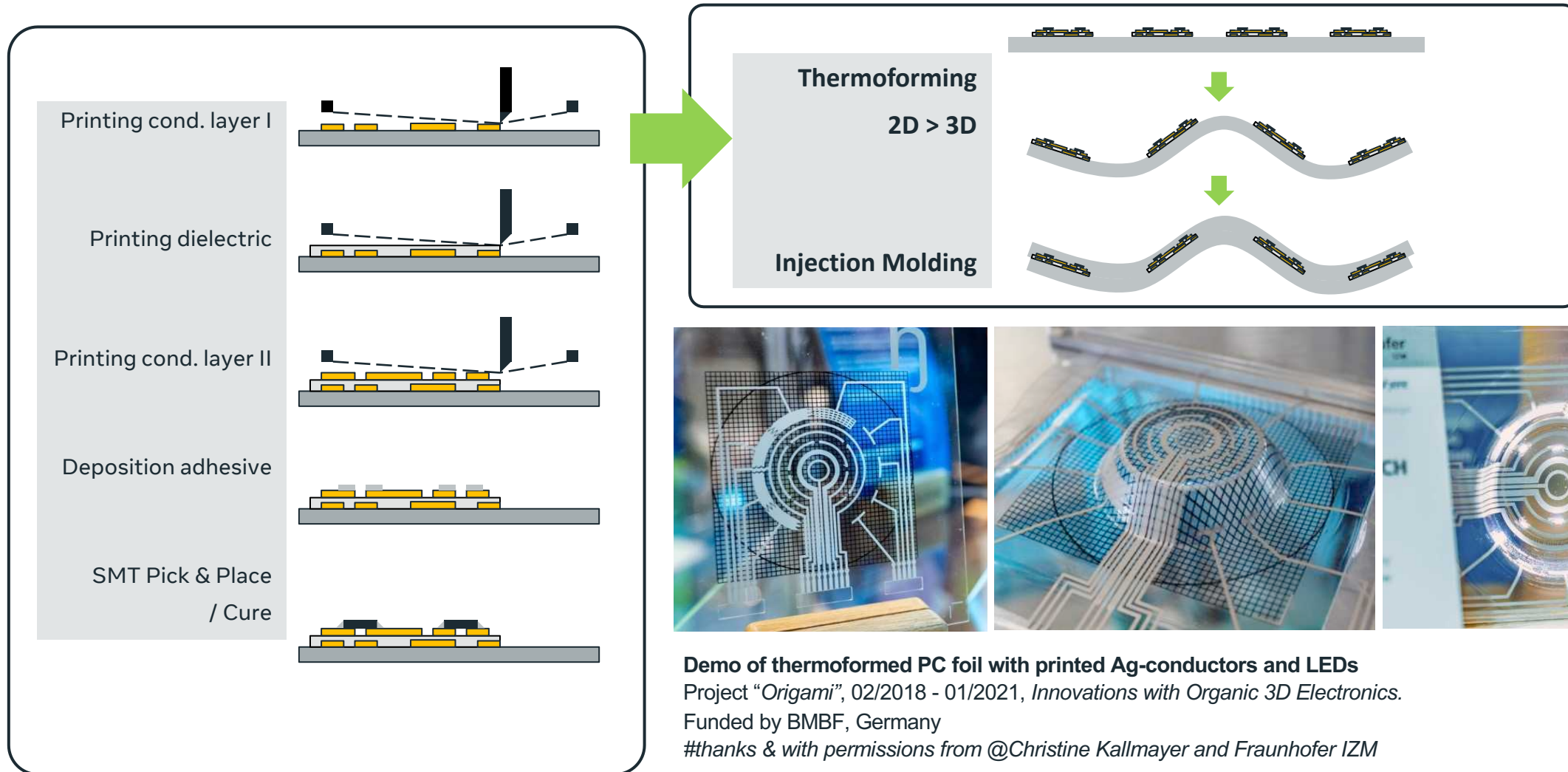
ASSEMBLY INTEGRATION



#thanks and with permissions from Girish Wable, Jabil

Benefits Leveraging **Wearability** **Integration** **Cost**

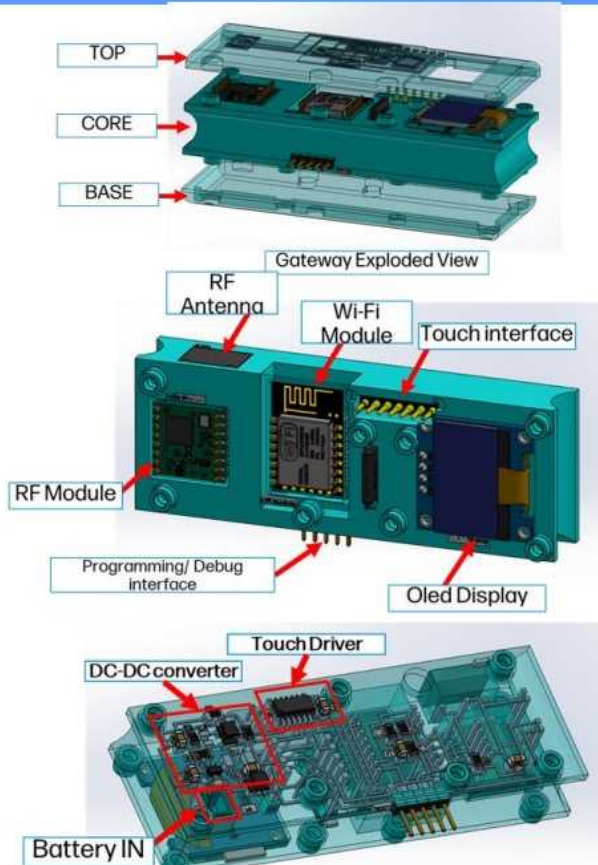
AME HI Applications Structural Electronics



Benefits Leveraging **Design Freedom**

AME HI Applications 3DPE Demonstrator

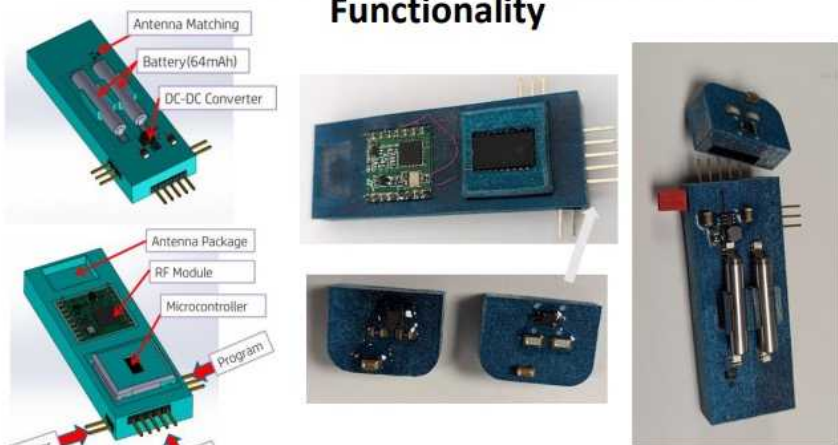
MJF 3DPE Demonstrator: Driving Device Complexity



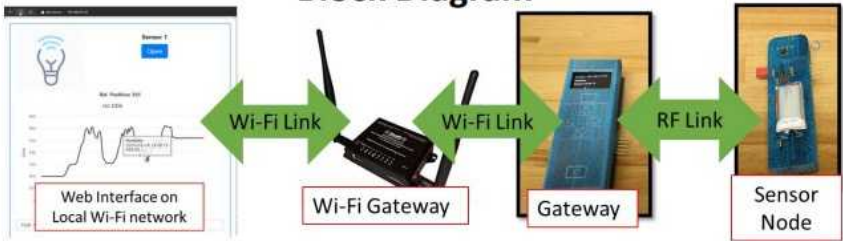
130 different nodes
47 signals



Modularity in Design to Increase Functionality



Gateway Node Sensor System Block Diagram

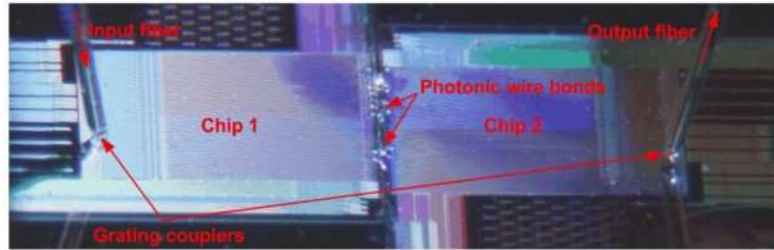


Benefits Leveraging 3D Integration

AME HI Applications Optical Wirebond

Specific Unmet HI Need

Interconnection Between Optical Chips & Output Fibers

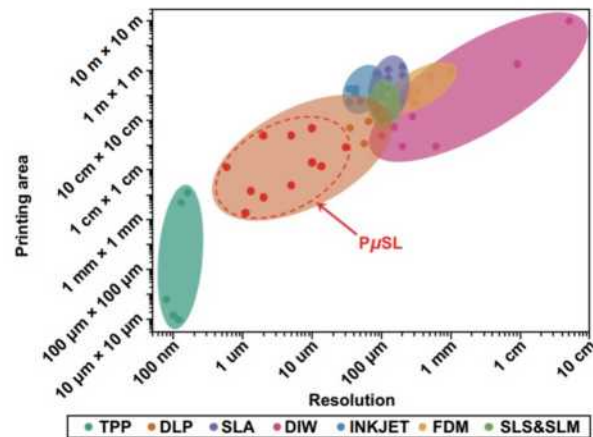


[DOI 10.1364/OE.20.017667](https://doi.org/10.1364/OE.20.017667)

Ultra-high Resolution 2-photon AME

TPP - Two-Photon Polymerization

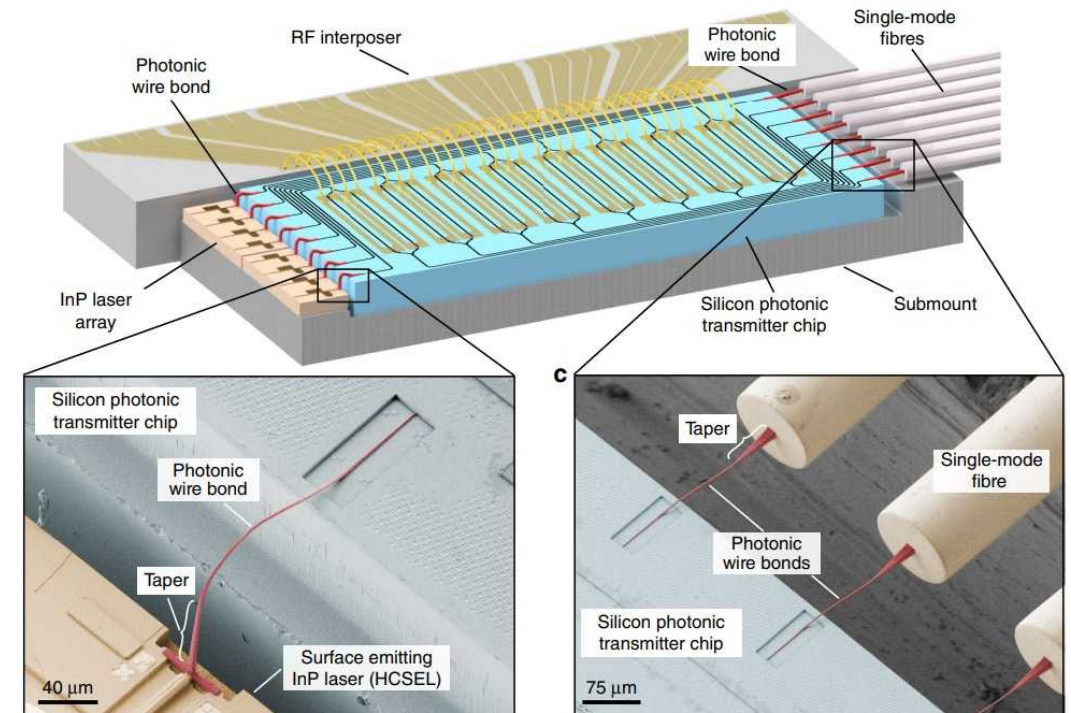
[DOI 10.1088/2631-7990/ab8d9a](https://doi.org/10.1088/2631-7990/ab8d9a)



Unique Solution Space

Index Matched Photo-resin

Automated Fabrication, Low losses, Passing Reliability Testing
400-700 GB/s Data Rate Demonstrations



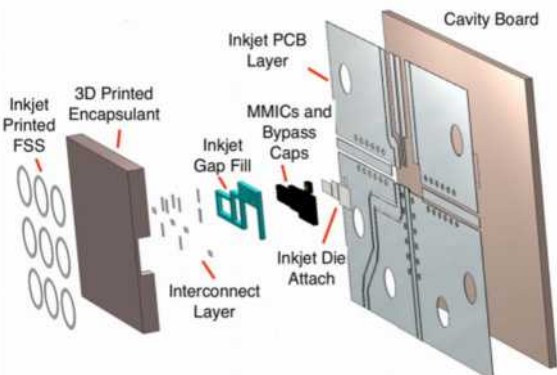
Photonic Wire-bond doi.org/10.1038/s41377-020-0272-5

Benefits Leveraging

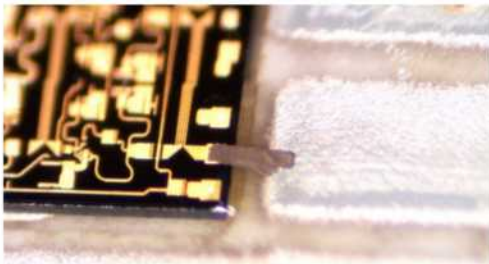
Unique Need + Unique Solution

AME HI Applications RF Structures

High performance monolithic microwave integrated circuit

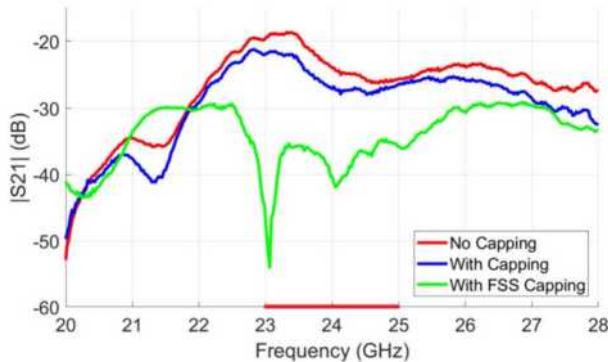
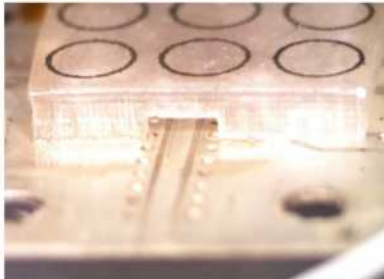


Inkjet printed Gap Fill & RF Interconnect



[M. Tentzeris, et al. *IEEE Trans Microwave Theory Tech.*, **2020**, 68, 2716-2724]

Inkjet printed FSS & SLA Printed Encapsulant

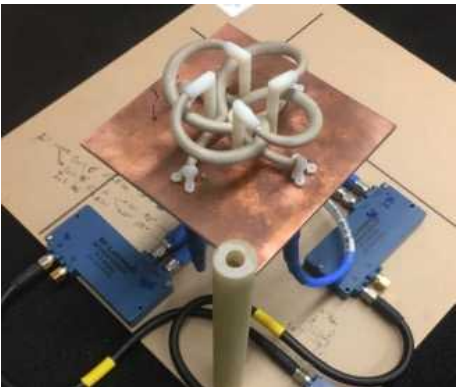


Inkjet & 3D Printed Broadband on-package Antenna



DOI 10.1109/ECTC.2018.00041

Fully 3D Antenna Geometries



DOI: [10.1109/ACCESS.2022.3202536](https://doi.org/10.1109/ACCESS.2022.3202536)

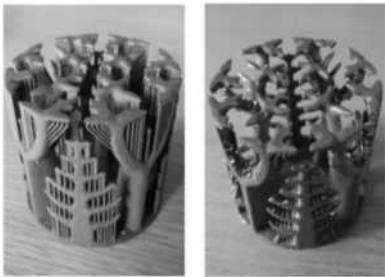
AME HI Applications Thermal

Air Cooled Heat Sinks



[<https://www.shutterstock.com/>]

Current



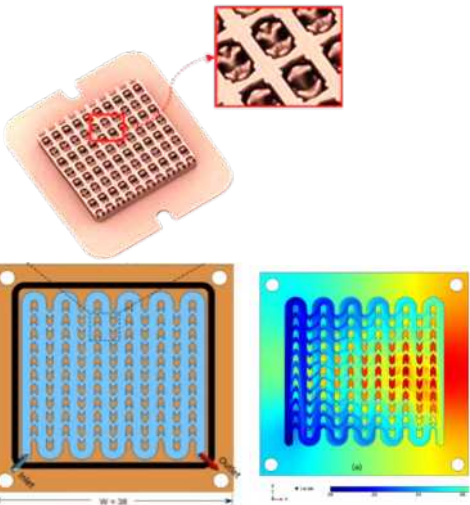
[Lazarov BS, Alexandersen J. Appl Energy. 2018;226(February): 330-339]

AM Thermal

Liquid Cooled Heat Sinks



Current

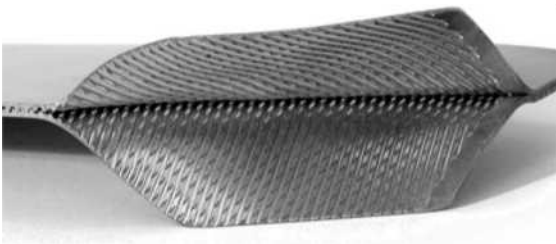


AM Thermal

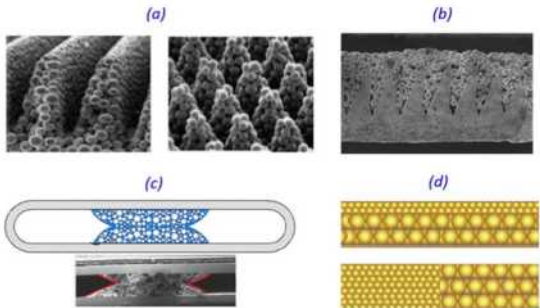
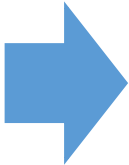
[Al-Neama AF, Thompson HM. Int J Heat Mass Transf. 2018;120:1213-1228]

Two Phase Convective Cooling

Current



[DOI: [10.1109/ITHERM.2006.1645335](https://doi.org/10.1109/ITHERM.2006.1645335)]

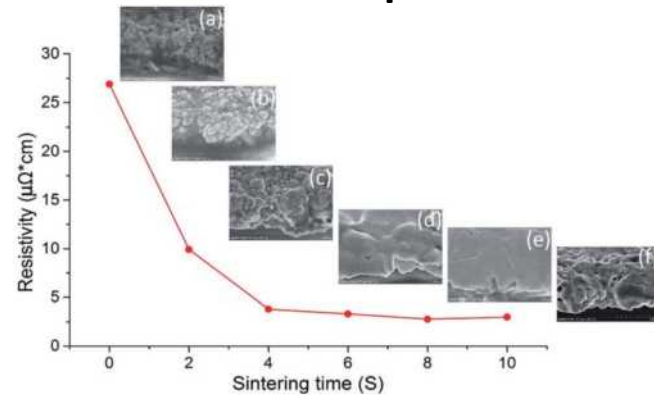


AM Thermal

[Jafari D, Wits. Renew Sustain Energy Rev. 2018; 91(April 2017):420-442]

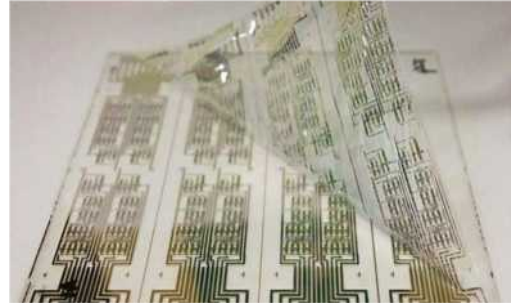
AME Growth Needs

Material Properties



[W. Gu, W. Yuan, et al. *RSC Adv.*, 2018, 8, 30215-30222]

Productivity & Yield



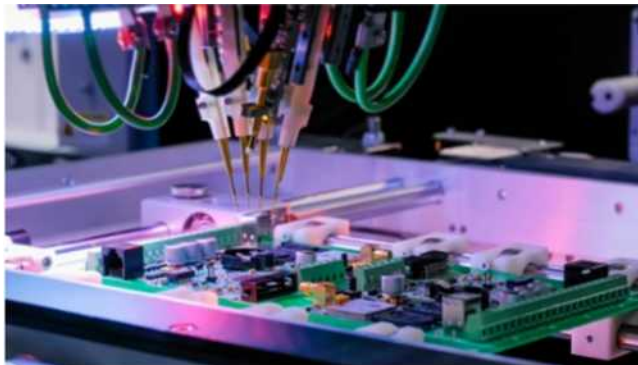
[<https://commons.wikimedia.org/wiki/>]

Product-Level Reliability



[<https://commons.wikimedia.org/wiki/>]

Automated Inspection & Correction



[<https://www.shutterstock.com/image-photo>]

Design Tools



[<https://www.shutterstock.com/image-photo>]

Integrated Manufacturing



Leveraging CapEx Investment & Adaptability to Current tooling

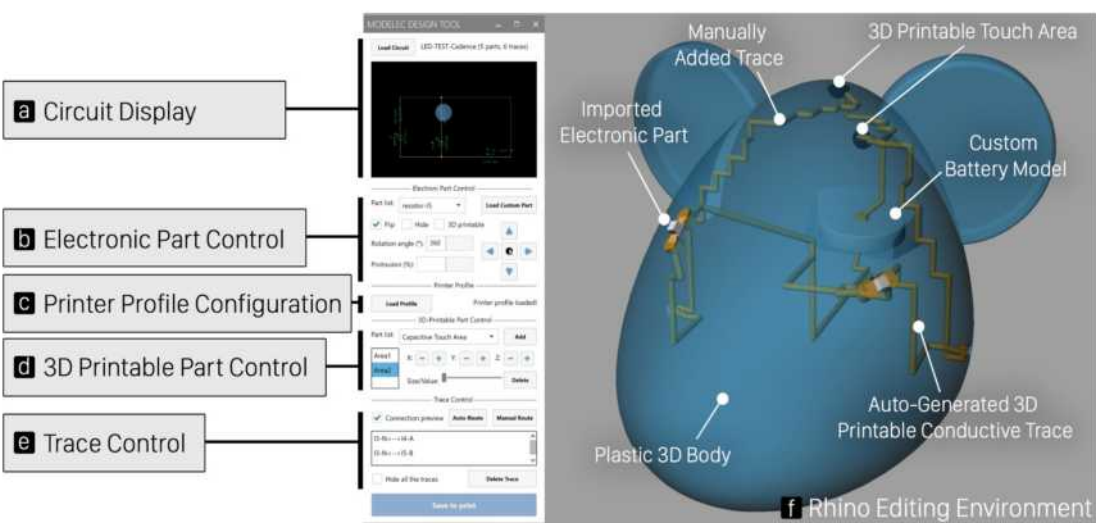
- Panel Sizes
- Planarity
- Alignment
- Form Factor
- Thermal Processes

[<https://www.microwavejournal.com/articles/31986>]

AME Growth Needs Design & Layout

Merging of EDA & CAD

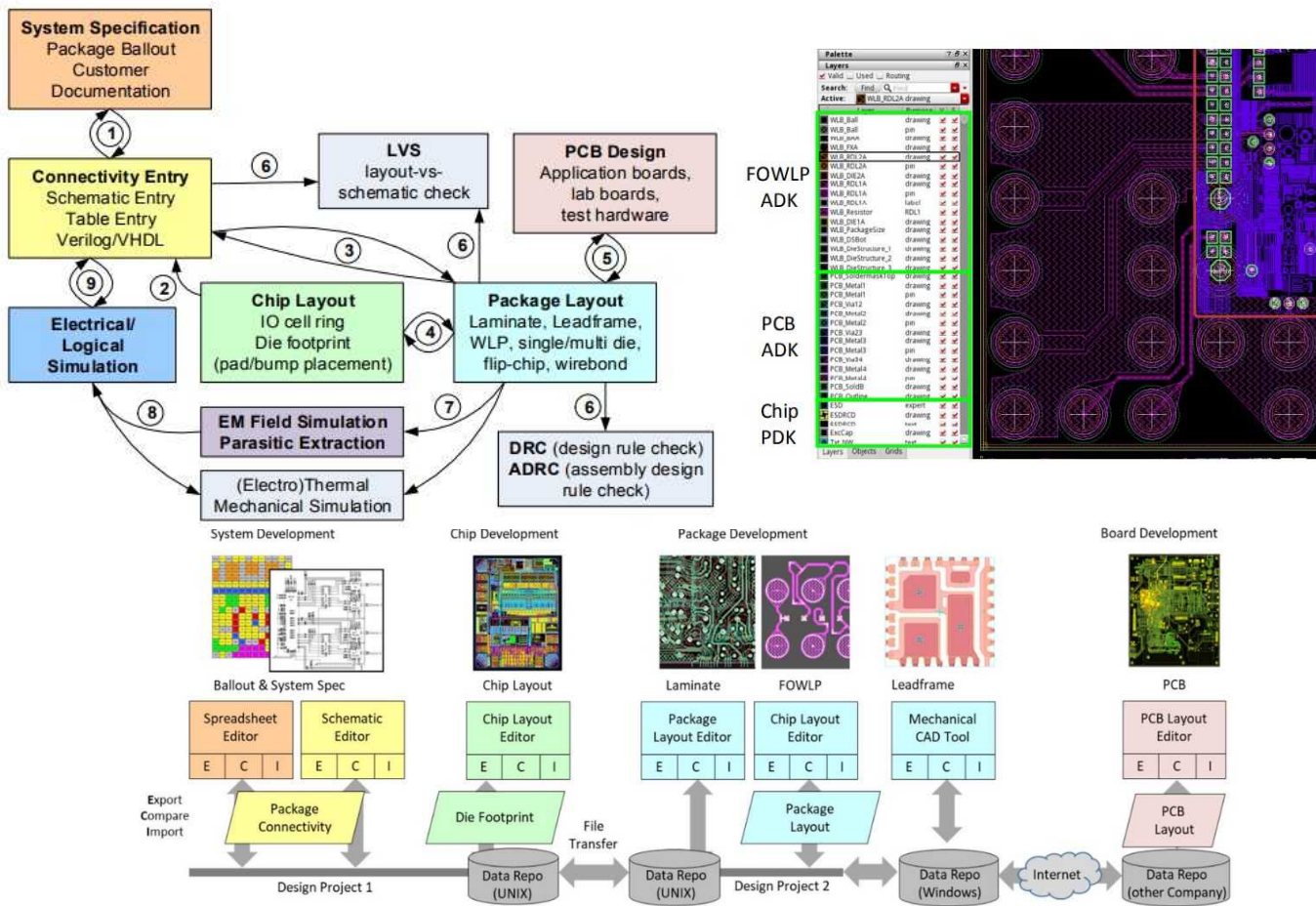
ModElec



[L. He, J. Wittkopf. Proc. ACM Interact. Mob. Wearable Ubiquitous Technol., Vol.5, No.4, Article159]

Integrated Co-Design Workflows

Example of Chip/Package/Board Co-design flow



DOI: 10.1109/ECTC32862.2020.00269

AME Growth Needs Reliability

Product Testing Considerations

Thermal Cycling

Typical Tested Operating Temperature Ranges

Military -55°C to 125°C

Automotive -40°C to 125°C

Industrial -40°C to 85°C

AEC-Q100 Lvl 2 -40°C to 105°C

High Temp/High Humidity

Level 1 - 85°C/85%RH - 1000 hrs

Drop Analysis

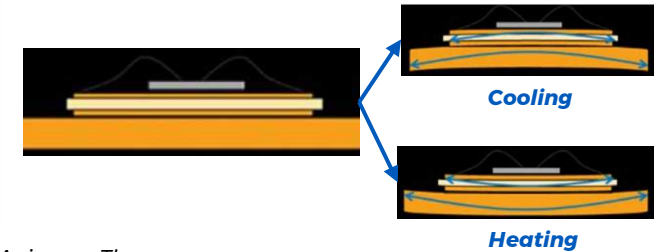
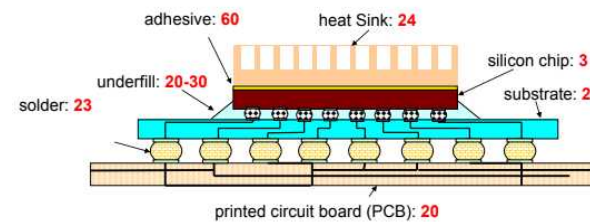
Per JESD22-B111A (2016)

Electromigration

Void & Hillock generation

Material CTE Considerations

CTE for Standard Packaging Materials ppm/°C



Ramdas, et al. (2019). Impact of Accelerated Thermal Aging on Thermo-Mechanical Properties of Oil-Immersed FR-4 Printed Circuit Boards.

Moisture Effects

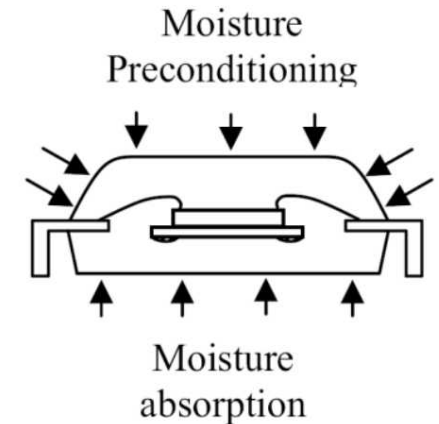
Humid Environment Effects

Material Swelling & Expansion

Moisture Density enhancement

Moisture Vaporization at Reflow

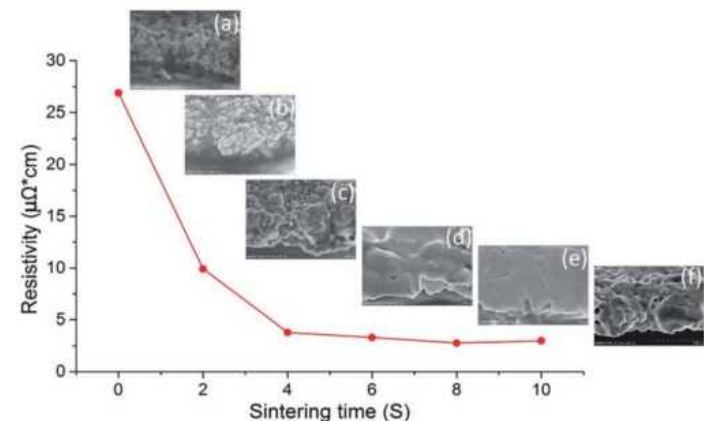
Corrosion



<https://doi.org/10.4233/uuid:9141f50e-5362-4b01-b06f-flcc3acd6543>

AME Growth Needs Material Properties

Conductor Properties



[W. Gu, W.Yuan, et al. *RSC Adv.*, 2018,**8**, 30215-30222]

Ink Type	Ink Composition	Conductivity
Carbon conductive ink	Carbon CNT	1.8×10^3 S/m $(5.03 \pm 0.05) \times 10^3$ S/m
Polymer conductive ink	PEDOT:PSS	8.25×10^3 S/m
Nano-silver ink	Ag-DDA Ag-PVP	3.45×10^7 S/m 6.25×10^6 S/m
Liquid metal ink	EGaIn $\text{Bi}_{35}\text{In}_{48.6}\text{Sn}_{16}\text{Zn}_{0.4}$	3.4×10^6 S/m 7.3×10^6 S/m

doi:10.3390/mi7120206

Ag bulk conductivity 6.3E7 S/m
Cu bulk conductivity 6.0E7 S/m

Dielectric Material Properties

Example - RDL Material Property Considerations

Characteristic	Ideal Properties	Polymer Family							
		Epoxy		BCB	Polyimide	Polybenzoxazole (PBO)	Fluro-polymer	Hydro-carbon	Metal Oxide
		Non PID	PID						
Electrical	Low loss Low D_k								
Physical	Ultra thin dry film (2-5 μm) Planar								
Thermal	Low-CTE Withstand 260 °C solder reflow								
Mechanical	High Elongation Low modulus								
Chemical	Resistance to chemicals Good adhesion								
Cost	Low Material and Processing Cost								
Reliability	Low Stress Low moisture absorption								

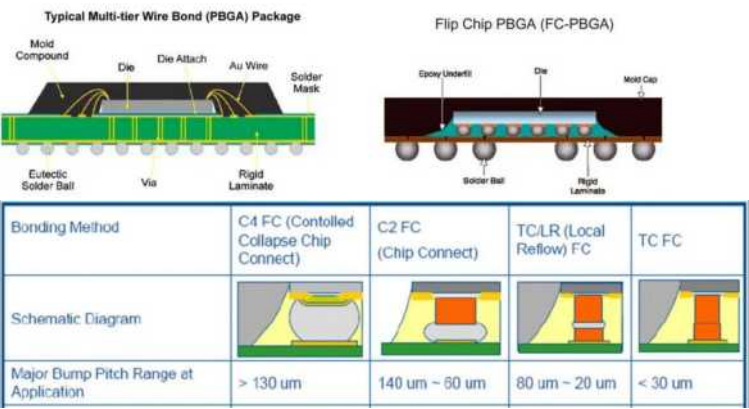
DOI 10.1109/ECTC32862.2020.00182

Both especially important for high-speed and high-frequency Applications!

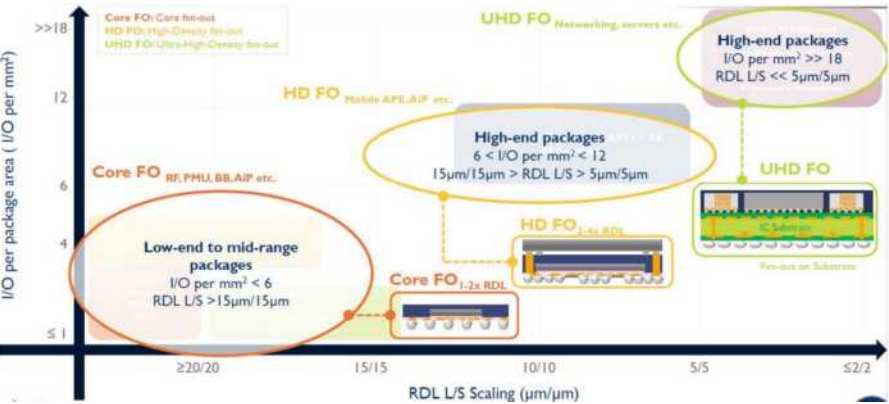
AME Growth Needs Application Targets

Advanced Packaging Targets

Interconnects



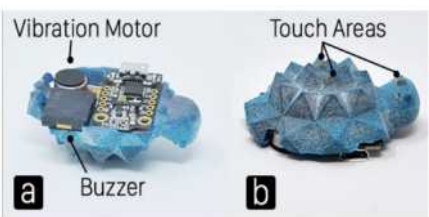
Redistribution Layers (RDL)



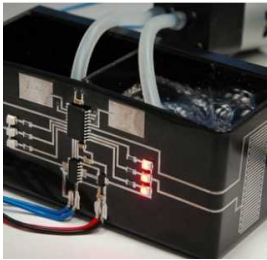
	2019	2023	2027
Link speed (Gbps) Serial Speeds [4]	50	100	200
BU dielectrics loss, Df'	0.007	0.004	0.002
BU dielectric roughness (Rq)	300~400 nm	150~200 nm	100~150 nm
Cu roughness (Rq)	350~400 nm	200~250 nm	50~100 nm

[HIR 2021 version (eps.ieee.org/hir), Ch. 8 & Ch. 23]

Application Targets Leveraging Unique AME Capabilities

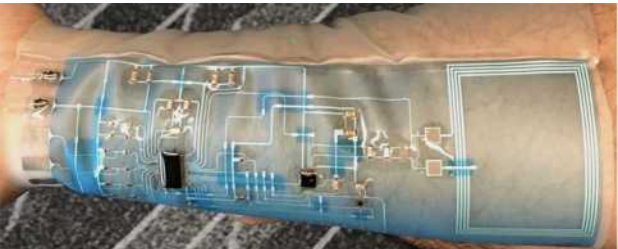


[L. He, J. Wittkopf. Proc. ACM Interact. Mob. Wearable Ubiquitous Technol., Vol.5, No.4, Article159]



DOI: 10.29026/oea.2018.170004

3D Form Factors

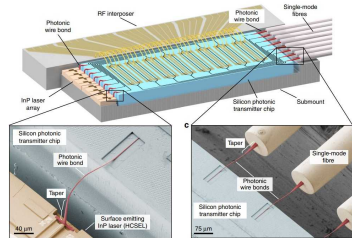


[https://www.jabil.com/blog/flexible-electronics.html]



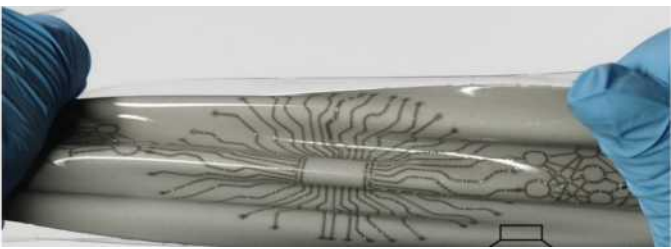
DOI 10.1186/s13104-015-0971-9

Individualized Designs



doi.org/10.1038/s41377-020-0272-5

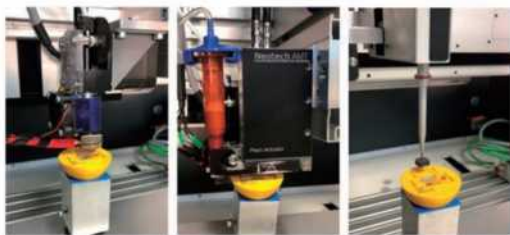
Meeting Unique Needs



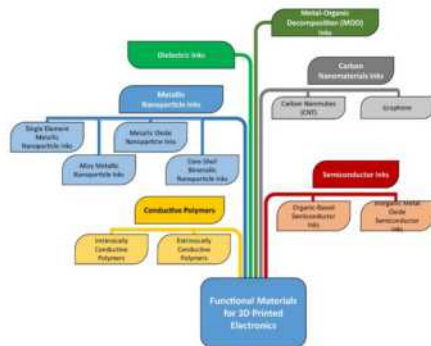
https://doi.org/10.1038/s41563-018-0084-7

Flex/Stretch Electronics

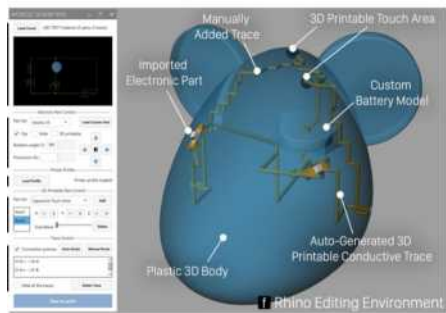
AME for Packaging & HI Impact



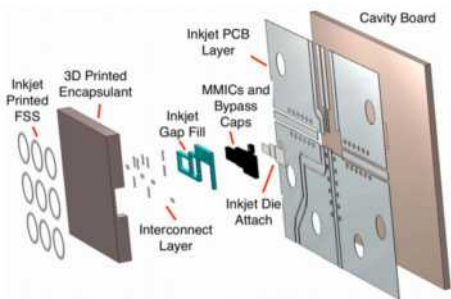
[M. Ankenbrand, M. Hedges. 2019 International Conference on Electronics Packaging (ICEP), 2019, pp. 273-278]



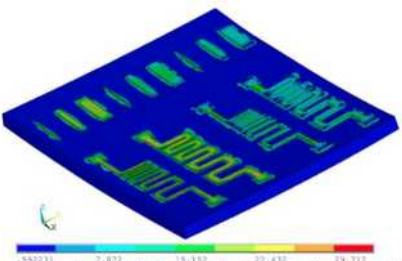
[H. Tan, C. Chua. Progress in Materials Science 127 (2022) 100945]



[L. He, J. Wittkopf. Proc. ACM Interact. Mob. Wearable Ubiquitous Technol., Vol.5, No.4, Article159]



[M. Tentzeris, et al. IEEE Trans Microwave Theory Tech., 2020, 68, 2716-2724]



[<https://doi.org/10.1016/j.microrel.2018.04.008>]

Manufacturing Methods & Integration + **Materials** + **Design Tools** + **Application Development** + **System Reliability**

Needing Concerted Advances from all for Adoption & Market Success